COURSE CODE(CREDITS): 17P1WGE102 (1)　　　　MAX. MARKS: 15

COURSE NAME: Ethics, Plagiarism & IPR Issues

COURSE INSTRUCTORS: Dr Hemant Sood　　　　MAX. TIME: 1 Hour

Note: (a) All questions are compulsory.

(b) Marks are indicated against each question in square brackets.

(c) The candidate is allowed to make Suitable numeric assumptions wherever required for solving problems

Q1 Apple's self-deploying screen protector has got a recent patent for this novel product and design. The company would like to file for the patent in India as well now, what is the procedure for getting this patent granted in India? Explain the criteria and methodology for the same. (4)

Q2. How you can protect the IP rights of the newly written book by Dr.R P Shekhar on **AI and its impact**? What are the modes of tackling the infringement if occurred after the registration of this IP? (3)

Q3. How does Intellectual Property Protection facilitate the development of a knowledge economy for your institution? What is the purpose of granting IPR? Explain with an example (3)

Q4. What is the need to develop patent databases? Which Indian patent database is largely utilized for accessing the information and why? (2)

Q5. How complete filling of the patent is compared with provisional filling for any product or process? Explain concerning its documents and procedure. (3)